

**IN THE SPECIFICATION:**

Please replace the paragraph beginning at page 6, line 7 with the following paragraph:

Fig. 1 is a diagram useful for understanding the operation of a resonant microcavity anode (RMA) type FED device 100 which can be used with the present invention. The FED device 100 is comprised of a cathode 101 formed from an emitter array 102 that is positioned on a silicon substrate 114. An RMA type anode or array or anodes 104 is spaced apart from the cathode and positioned behind glass 108. The anode is preferably comprised of a thin film phosphor 106 which can be formed between dielectric mirrors 110. As electrons 118 excite the thin film phosphor 106, they cause ~~causing~~ the emission of light through glass 108 in the direction of arrow 116 . A control grid may also be provided for modulating the intensity of electrons 118 directed toward anode 104.